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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/820,770	04/09/2004	Ichiro Koiwa	OKI.651	8824
20987	7590	09/29/2006	EXAMINER	
VOLENTINE FRANCOS, & WHITT PLLC ONE FREEDOM SQUARE 11951 FREEDOM DRIVE SUITE 1260 RESTON, VA 20190				HOANG, QUOC DINH
			ART UNIT	PAPER NUMBER
			2818	

DATE MAILED: 09/29/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)
	10/820,770	KOIWA, ICHIRO
	Examiner	Art Unit
	Quoc D. Hoang	2818

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

1) Responsive to communication(s) filed on 19 July 2006.
 2a) This action is FINAL. 2b) This action is non-final.
 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4) Claim(s) 2-8, 15, 16 and 18-27 is/are pending in the application.
 4a) Of the above claim(s) 4-6, 19-22 and 24-27 is/are withdrawn from consideration.
 5) Claim(s) _____ is/are allowed.
 6) Claim(s) 2, 3, 7, 8, 15, 16, 18, 23 and 27 is/are rejected.
 7) Claim(s) _____ is/are objected to.
 8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

9) The specification is objected to by the Examiner.
 10) The drawing(s) filed on _____ is/are: a) accepted or b) objected to by the Examiner.
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 a) All b) Some * c) None of:
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

1) Notice of References Cited (PTO-892)
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
 3) Information Disclosure Statement(s) (PTO/SB/08)
 Paper No(s)/Mail Date _____.
 4) Interview Summary (PTO-413)
 Paper No(s)/Mail Date. _____.
 5) Notice of Informal Patent Application
 6) Other: _____.

DETAILED ACTION

Response to Amendment

1. Amendment filed on 07/19/2006 has been entered. Claims 2-8, 15, 16 and 18-27 are pending in the application. The examiner agrees that claims 15, 16 and 18, along with claims 2, 3, 7, 8, 23 and 27, as reading on elected species I – Fig. 5.

Claim Rejections - 35 USC § 103

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

3. Claims 2, 3, 7, 8, 15, 16, 18, 23 and 27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Aoki et al., (US Pat No. 6,033,953) (hereinafter "Aoki") in view of Lu., (US Pat No. 5,679,596).

Regarding claim 2, Aoki teaches a ferroelectric capacitor comprising:

a bottom electrode (38) (col. 1, lines 14-57 and Fig. 14);

a plurality of projection electrodes (convex parts 38a) formed on the bottom electrode (col. 1, lines 14-57 and Fig. 14);

a ferroelectric layer (40) formed on the bottom electrode and the projection electrodes (col. 1, lines 14-57 and Fig. 14); and

a top electrode (37) formed on the ferroelectric layer, wherein a thickness of the ferroelectric layer on the projection electrodes is less than a thickness of the ferroelectric layer on the bottom electrode (col. 1, lines 14-57 and Fig. 14).

Aoki teaches a plurality of projection electrodes, but fails to teach wherein spacing between central portions of each projection electrode has a range from 10 % to 20% of a size of the ferroelectric capacitor.

However, Lu teaches wherein spacing between central portions of each projection electrode (14b) has a range from 1.5 % to 75% of a size of the ferroelectric capacitor (col. 4, line 50 through col. 5, line 65 and Fig. 5). *It is noted that the size of the ferroelectric capacitor is considered the width (2,000-10,000 Å) of the bottom electrode 11 (col. 4, lines 40-43), the width of the projection electrode 14b is between about 50-500 Å (col. 5, lines 17-18), and the spaces 14a between the projection electrode 14b are between about 100-1000 Å (col. 5, lines 19-21). Hence, after calculating, the spacing between central portions of each projection electrode 14b has a range from 1.5 % to 75% of a size of the ferroelectric capacitor.* Since Aoki and Lu are all from the same field of endeavor, the purpose disclosed by Lu would have been recognized in the pertinent art of Aoki. It would have been obvious to a person of ordinary skill in the art at the time of the invention was made to provide spacing between central portions of each projection electrode in order to increase the surface area of the bottom electrode, therefore to obtain the desired increased capacitance as taught by Lu, column 5, lines 24 through col. 6, line 3. Although Lu's percentage range (1.5 % to 75%) is not the claimed range (10 % to 20%), this does not define patentable over Aoki in view of Lu

since it has been held where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable range involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

Regarding claim 3, Aoki teaches a ferroelectric capacitor comprising:

a bottom electrode (38) (col. 1, lines 14-57 and Fig. 14);
a plurality of projection electrodes (convex parts 38a) formed on the bottom electrode (col. 1, lines 14-57 and Fig. 14);
a ferroelectric layer (40) formed on the bottom electrode and the projection electrodes (col. 1, lines 14-57 and Fig. 14); and
a top electrode (37) formed on the ferroelectric layer, wherein a thickness of the ferroelectric layer on the projection electrodes is less than a thickness of the ferroelectric layer on the bottom electrode (col. 1, lines 14-57 and Fig. 14).

Aoki teaches a plurality of projection electrodes, but fails to teach wherein wherein a size of each projection electrode has a range from 5 % to 10% of a size of the ferroelectric capacitor.

However, Lu teaches wherein a size of each projection electrode (14b) has a range from 0.5 % to 25% of a size of the ferroelectric capacitor (col. 4, line 50 through col. 5, line 65 and Fig. 5). *It is noted that the size of the ferroelectric capacitor is considered the width (2,000-10,000 Å) of the bottom electrode 11 (col. 4, lines 40-43), the size of each projection electrode is considered the width of the projection electrode 14b, which is between about 50-500 Å (col. 5, lines 17-18). Hence, after calculating, a size of each projection electrode has a range from 0.5 % to 25% of a size of the*

ferroelectric capacitor. Since Aoki and Lu are all from the same field of endeavor, the purpose disclosed by Lu would have been recognized in the pertinent art of Aoki. It would have been obvious to a person of ordinary skill in the art at the time of the invention was made to provide a size of each projection electrode has a range from 5 % to 10% of a size of the ferroelectric capacitor in order to increase the surface area of the bottom electrode, therefore to obtain the desired increased capacitance as taught by Lu, column 5, lines 24 through col. 6, line 3. Although Lu's percentage range (0.5 % to 25%) is not the claimed range (5 % to 10%), this does not define patentable over Aoki in view of Lu since it has been held where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable range involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

Regarding claim 7, Aoki teaches a ferroelectric capacitor comprising:

a bottom electrode (38) (col. 1, lines 14-57 and Fig. 14);
a plurality of projection electrodes (convex parts 38a) formed on the bottom electrode (col. 1, lines 14-57 and Fig. 14);
a ferroelectric layer (40) formed on the bottom electrode and the projection electrodes (col. 1, lines 14-57 and Fig. 14); and
a top electrode (37) formed on the ferroelectric layer, wherein a thickness of the ferroelectric layer on the projection electrodes is less than a thickness of the ferroelectric layer on the bottom electrode (col. 1, lines 14-57 and Fig. 14).

Aoki teaches a plurality of projection electrodes, but fails to teach wherein the projection electrodes are arranged evenly spaced on the bottom electrode.

However, Lu teaches wherein the projection electrodes (14b) are arranged evenly spaced on the bottom electrode 11 (col. 4, line 50 through col. 5, line 65 and Fig. 5). *It is noted that the evenly spaced between the projection electrodes 14b is the width of the crevice or space 14a (col. 5, lines 19-21).* Since Aoki and Lu are all from the same field of endeavor, the purpose disclosed by Lu would have been recognized in the pertinent art of Aoki. It would have been obvious to a person of ordinary skill in the art at the time of the invention was made to provide evenly spaced between the projection electrodes in order to increase the surface area of the bottom electrode, therefore to obtain the desired increased capacitance as taught by Lu, column 5, lines 24 through col. 6, line 3.

Regarding claim 8, Aoki teaches wherein the bottom electrode 38 and the projection electrodes 38a are made of a same material (platinum) (col. 1, lines 50-55 and Fig. 14).

Regarding claim 15, Aoki teaches a ferroelectric capacitor comprising:
a first electrode (38) (col. 1, lines 14-57 and Fig. 14);
a second electrode (37) (col. 1, lines 14-57 and Fig. 14);
a ferroelectric layer (40) which is sandwiched between the first electrode and the second electrode (col. 1, lines 14-57 and Fig. 14);
a plurality of third electrodes (convex parts 38a) formed between the first electrode and the second electrode, wherein a thickness of the ferroelectric layer on the projection electrodes is less than a thickness of the ferroelectric layer on the bottom electrode (col. 1, lines 14-57 and Fig. 14);

Aoki teaches a plurality of third electrodes, but fails to teach wherein the third electrodes are arranged evenly spaced.

However, Lu teaches wherein the third electrodes (14b) are arranged evenly spaced (col. 4, line 50 through col. 5, line 65 and Fig. 5). *It is noted that the evenly spaced between the projection electrodes 14b is the width of the crevice or space 14a (col. 5, lines 19-21).* Since Aoki and Lu are all from the same field of endeavor, the purpose disclosed by Lu would have been recognized in the pertinent art of Aoki. It would have been obvious to a person of ordinary skill in the art at the time of the invention was made to provide evenly spaced between the third electrodes in order to increase the surface area of the first electrode, therefore to obtain the desired increased capacitance as taught by Lu, column 5, lines 24 through col. 6, line 3.

Regarding claim 16, Aoki teaches wherein the third electrodes (14b) are formed on the first electrode (col. 4, line 50 through col. 5, line 65 and Fig. 5).

Regarding claim 18, Aoki teaches wherein the first electrode (38) and the third electrodes (38a) are made of a same material (platinum) (col. 1, lines 50-55 and Fig. 14).

Regarding claim 23, Aoki teaches wherein the bottom electrode 38 and the projection electrodes 38a are made of a same material (platinum) (col. 1, lines 50-55 and Fig. 14).

Regarding claim 27, Aoki teaches wherein the bottom electrode 38 and the projection electrodes 38a are made of a same material (platinum) (col. 1, lines 50-55 and Fig. 14).

Conclusion

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Quoc Hoang whose telephone number is (571) 272-1780. The examiner can normally be reached on Monday-Friday from 8.00 AM to 5.00 PM.

If attempt to reach the examiner by telephone are unsuccessful, the examiner's supervisor, MinSun Harvey can be reached on (571) 272-1835. The fax phone numbers of the organization where this application or proceeding is assigned are (571) 273-8300 for regular communications and (571) 273-8300 for After Final communications.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Quoc Hoang
Patent examiner/AU 2818

Quoc Hoang

09/24/2006